



Field Emission Mitigation via Plasma Processing in 9-cell TESLA-type Cavities

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- Introduction
- Plasma ignition in 1.3GHz TESLA-shaped cavities
 - New method to control plasma ignition
 - RF measurements at different pressures with Neon and Argon
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 - Effect of plasma on N-doping
 - Effect of plasma on contaminated cavities
- Conclusions
 - Future work



Collaboration for LCLS-II Plasma Processing



- Adapt the ORNL plasma cleaning technique to LCLS-II cavities and cryomodules
- Provide a system capable of efficiently process LCLS-II cavities/cryomodules





- Simulation for applicability of ORNL plasma processing to LCLS-II cavities
- Use the system to perform cleaning in the accelerator tunnel

- Successful experience with plasma processing
- Guidance for design and sample studies for LCLS-II plasma cleaning

Project supported by DOE - Basic Energy Sciences (BES)



In-situ plasma processing



Procedure can be applied at room temperature in-situ in the cryomodules



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Plasma Processing Methodology

- Reducing FE by increasing work function of cavity RF surface
 - Hydrocarbons and adsorbates lower work function of Nb
- Enabling operation at higher accelerating gradient

Ne-O Plasma Pump M. Doleans et al. NIMA 812 (2016) 50-59

 $O_2 + C_x H_v \rightarrow CO + CO_2 + H_2O$

Increasing Φ by 10 % means increasing E_{acc} of about 15 %

$$j = \beta \frac{AE^2}{\Phi} e^{-B \frac{\Phi^{3/2}}{\beta E}}$$
$$dj = 0 \qquad \frac{dE_{acc}}{E_{acc}} \approx \frac{3}{2} \frac{d\Phi}{\Phi}$$

J: current density

- E: surface electric field
- Φ : work function
- β : enhancement factor (~10 to 100)

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A,B: constants

Plasma ignition in SRF cavities

Glow discharge is ignited one cell per time \rightarrow necessary to:

- maximize E field in one cell
- select cell of ignition

SNS method: Dual Tone excitation to **ignite the plasma**

 Superposition of two frequencies of the fundamental passband to create an asymmetry and maximize the electric field in one cell to select it as cell of ignition

M. Doleans, J. Appl. Phys. 120, 243301 (2016)

FNAL method: Dual Tone excitation to **transfer the plasma**

 Ignition in central cell + superposition of higher order modes to move the plasma inside the cavity

P. Berrutti, J. Appl. Phys. 126, 023302 (2019)



Field enhancement at LCLS-II FPC

Due to geometry: intense field enhancement at the fundamental power coupler

9-cell plasma ignition	
Total P _f [W]	350
E _{coupler} [kV/m]	90
E _{cavity} [kV/m]	12





Due to low coupling factor at room temperature less than 1% of the power is transmitted to the cavity ($Q_{Nb} = 1 \cdot 10^4$, $Q_{ext} = 3 \cdot 10^7$).



This could result in: - no plasma ignition - plasma ignition in the coupler

P. Berrutti | TTC Meeting 2018 at RIKEN Nishina Center



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Plasma ignition in TESLA-shaped cavities using HOMs

New idea: ignite the plasma using HOMs!



HOMs (higher order modes): good coupling at room temperature Plasma can be ignited using only few Watts!

For the first two HOM pass-bands:

- Coupling factor: 0.01<β<1.17
- Reflection coefficient $0.006 < |\Gamma|^2 < 0.94$
- Plasma is ignited cell by cell, not in the entire cavity
- Dual tone excitation to transfer the plasma: using a superposition of HOMs it is possible to transfer the plasma through adjacent cells



Example of plasma transfer from cell #5 to #6

- 1. Cell #5 is ignited with mode 2D-1
- 2. Mode1D-3 is added to create asymmetry between cell #4 and cell #6
- 3. E field is still maximum in cell 5: Mode 2D-1 can now be switched off and the plasma remains ignited in cell #5
- 4. Add mode 1D-6 to 1D-3: E field is now maximum in cell #6, the plasma moves from 5 to 6
- 5. Switch off mode 1D-3, plasma remains ignited in cell #6.



P. Berrutti, B. Giaccone et al., J. Appl. Phys. 126, 023302 (2019)



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Cell of ignition: detected with frequency shift measurements

Method to locate the cell where plasma is ignited without use of cameras:

- 1. The **frequency shift** $\delta \omega$ of the first dipole pass-band due to plasma ignition is **measured**
 - $\delta \omega$ depends on:
 - Change in **dielectric constant** due to plasma ($\epsilon \propto \eta$)
 - Intensity of the electric field of the mode in the cell of ignition

$$\frac{\delta\omega}{\omega} \approx \frac{1}{2} \frac{\iiint_{plasma} \eta E^2 dV}{\iiint_{cavity} E^2 dV}, \qquad \eta = \frac{\omega_{plasma}^2}{\omega_{RF}^2}$$

2. Measured $\delta \omega$ is compared with $\delta \omega$ calculated simulating the glow discharge in each cell of the cavity

Cell of ignition: detected with frequency shift measurements

Developed a Labview program that measures $\delta \omega$ and compares it to simulated $\delta \omega$ and **identifies cell of ignition**





Plasma cleaning apparatus



- Cleaning is performed at room temperature with 75-200 mTorr of Ne-O₂
- Cavities are assembled with valves on both end sides, for injection and evacuation of the gas
- Neon and Oxygen are sent to the cavity mixed (few % of O₂)
- RGA is used to analyze by-products



RF measurements: cavity backfilled with Neon or Argon

Example of Neon plasma ignition in each one of the 9 cells





Neon and Argon ignition curves

- Plasma ignition as a function of pressure monitored for both Neon and Argon
- Verified that the risk of igniting the plasma at the HOM coupler is negligible



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Plasma processing studies in artificially contaminated cavity

- 1st test goal: remove hydrocarbon contamination with plasma cleaning
- We draw 8 "dots" with both red and black permanent markers around the iris of the first cell of a 9-cell LCLS-II cavity



EDS analysis of black Sharpie ink





Contaminated cell (#1) has been processed for ≈ 19 hours total





Initial state

After 5h of plasma cleaning

After 19h of plasma cleaning





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N-doped single cell: RF results before and after plasma processing

<u>Scope</u>: study effect of plasma processing on Q-factors on N-doped cavities

N-doped cavity processed for 16h with Ne-O₂ plasma.





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Studies of plasma processing in Contaminated cavities

Plasma processing applied in some field emitting/contaminated cavities:

- Carbon contamination: introduction of Aquadag contamination on the iris of the cavity
- Naturally FE cavities: plasma processing applied on a naturally field emitting cavities, as received from the vendor
- Vacuum failure: simulation of vacuum accident to ATM to introduce field emitters
 - Inside Clean room
 - Outside Clean room



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Controlled introduction of carbon contamination

 Small drop of Aquadag (carbon-based conductive paint) introduced using a clean Nb wire at the iris of a single-cell cavity



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Carbon contamination: RF results before and after plasma processing

Scope: study the removal of Carbon contamination

Single cell cavity processed for 17h with Ne-O₂ plasma.



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Carbon contamination: RF results before and after plasma processing

Scope: study the removal of Carbon contamination

• Single cell cavity processed for 17h with Ne-O₂ plasma.



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Carbon contamination: RF results before and after plasma processing



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Naturally Field Emitting cavity: RF results before and after plasma processing (1) Scope: study the effect of Plasma processing on natural field emission

9-cell cell cavity, each cell processed for <2h with Ne-O₂ 1000000 plasma. 100000 10000 Q₀ - Before Plasma 1E10 1000 Rad Top - Before Plasma Rad Bot - Before Plasma 1.



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Naturally Field Emitting cavity: RF results before and after plasma processing (1) <u>Scope</u>: study the effect of Plasma processing on natural field emission

9-cell cell cavity, each cell processed for <2h with Ne-O₂ 1000000 plasma. 100000 10000 Q₀ - Before Plasma Q₀ - After Plasma Radiation [mR/hr] 1E10 -1000 Rad Top - Before Plasma Rad Bot - Before Plasma 1. -Rad Top - After Plasma 100 ő Rad Bot - After Plasma 1. 10 0.1 1E9 0.01 2 12 13 14 15 16 17 18 3 9 11 E_{acc} [MV/m]

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Naturally Field Emitting cavity: RF results before and after plasma processing (2)

<u>Scope</u>: study the effect of Plasma processing on natural field emission

9-cell cell cavity, each cell processed for <2h with Ne-O₂ 1E11 100 plasma. Q₀ - Contaminated Rad Top - Contaminated Rad Bot - Contaminated 10 Radiation [mR/hr] ര് 0.1 1E10 0.01 18 20 2 10 16 0 6 8 12 14 E_{acc} [MV/m] 🛟 Fermilab

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Naturally Field Emitting cavity: RF results before and after plasma processing (2) Scope: study the effect of Plasma processing on natural field

emission



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Naturally Field Emitting cavity: RF results before and after plasma processing (2) Scope: study the effect of Plasma processing on natural field emission



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Simulated vacuum failure in clean room: RF results before and after plasma processing Scope: study the effect of plasma on natural contamination due to venting

• 9-cell cavity: each cell processed for <2h with Ne-O₂



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Simulated vacuum failure in clean room: RF results before and after plasma processing <u>Scope</u>: study the effect of plasma on natural contamination due to venting

• 9-cell cavity: each cell processed for <2h with Ne-O₂



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Studies of plasma processing in Contaminated cavities

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 - Inside Clean room
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Simulated vacuum failure outside clean room: RF results before and after plasma processing

<u>Scope</u>: study the effect of plasma on natural contamination due to venting

9-cell cavity, each cell processed for <2h with Ne-O₂ 3.5E10 10⁶ plasma. 10⁵ 3E10 10^{4} 2.5E10 ¹⁰⁰ ¹⁰ ¹⁰¹ ¹⁰⁰ ¹⁰⁰ ¹⁰⁰ ¹⁰⁰ ¹⁰⁰ ¹⁰⁰ 2E10 ő 1 Q₀ - Baseline Q₀ - Contaminated 1.5E10 Rad Top - Contaminated Rad Bot - Contaminated 10⁻¹ 10⁻² 1E10 2 12 13 14 15 16 17 18 19 3 11 E_{acc} [MV/m] 🛟 Fermilab

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Simulated vacuum failure outside clean room: RF results before and after plasma processing

<u>Scope</u>: study the effect of plasma on natural contamination due to venting

9-cell cavity, each cell processed for <2h with Ne-O₂ 3.5E10 10⁶ plasma. 10⁵ 3E10 10^{4} 2.5E10 10⁰ 10¹ 10¹ 10¹ 10¹ Radiation [mR/hr] 2E10 ő Q₀ - Baseline Q₀ - Contaminated Q₀ - After Plasma 1.5E10 -Rad Top - Contaminated Rad Bot - Contaminated Rad Top - After Plasma 10^{-1} Rad Bot - After Plasma 10⁻² 1E10 12 13 14 15 16 17 18 19 2 3 E_{acc} [MV/m] 🛟 Fermilab

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Example of Residual Gas Analyzer spectrum

- RGA spectrum measured during first day of plasma processing on 9-cell cavity
- Peaks in C, CO, CO₂ indicate when the glow discharge is transferred to a new cell
- Carbon-related peaks decrease to background level in ≈30min





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Conclusions

- HOMs ignition method: substantially reduces P_{FWD} and enables the procedure on 9-cell TESLA-shaped cavities
 - Developed procedure to **locate plasma** in the cavity for in-situ application
- Studied different pressures and gases: identified optimal pressure range for adequate plasma control
- Viewport cavity: very successful → hydrocarbon contamination removal using Ne-O₂ glow discharge.
 - Developed a first recipe in terms of pressure, O_2 %, plasma density and duration.
- N-doped cavity: Plasma processing preserved High Q & quench field
- Contaminated cavities treated with plasma processing and RF tested before and after:
 - <u>Carbon contaminated cavity</u>: gradient successfully recovered
 - <u>Natural FE</u>: 1 out of 2 showed removal of FE
 - <u>Vacuum failure simulation</u>: <u>Inside clean room</u>: FE successfully removed
 - <u>Outside clean room</u>: repeated on 3 cavities, showed **moderate increase in performance**

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Future work

- Cavities exposed to simulated vacuum failure: collect and analyze particles that are still present after plasma cleaning
- Continue plasma process and cold-test 9-cell 1.3GHz TESLA-shaped cavities to acquire statistics on effectiveness in terms of field emission reduction
- Use viewport cavity with controlled, visible and reproducible carbon contamination to optimize processing parameters:
 - Pressure
 - Duration
 - O₂ concentration
 - Plasma density



Thank you!



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RF measurements: Tuning of plasma intensity

Both detection and tuning are related to $\delta \omega$ of the eigenfrequencies caused by the plasma

$$\frac{\delta\omega}{\omega} \approx \frac{1}{2} \frac{\iiint_{plasma} \eta E^2 dV}{\iiint_{cavity} E^2 dV},$$

$$\eta = \frac{\omega_{plasma}^2}{\omega_{RF}^2}$$

Mode 1-5 cell #5



To tune the intensity can be varied:

• P_{FWD}

• ω_{RF} sent to the cavity

 $\Delta f_{max} \approx 15-20 \text{MHz}$





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Single cell – plasma ignition – N-doping test